



## JVST A Call for Research Articles

### Special Issue on Synchrotron Radiation and Atomic Layer Deposition for Advanced Materials

JVST A is soliciting research articles for publication in the March/April 2018 Special Issue on Synchrotron Radiation and Atomic Layer Deposition for Advanced Materials.

This special issue is planned in collaboration with the E-MRS Fall Meeting 2017 to be held at Warsaw University of Technology in Poland, from September 18-21, 2017. The Special Issue will be dedicated to the science and technology of the use of synchrotron radiation to advance the state-of-the-knowledge in atomic layer deposition of materials. While many articles are expected to be based on material presented at the E-MRS Fall Meeting 2017, research articles that are on topic but were not presented at this meeting are also welcome: the special issue will be open to all articles on the science and technology of Synchrotron Radiation and Atomic Layer Deposition for Advanced Materials.

#### Guest Editors:

Dr. Malgorzata Kot  
BTU Cottbus-  
Senftenberg  
(Germany)

Dr. Claudia Wiemer  
Laboratorio MDM,  
IMM CNR (Italy)

#### Manuscript

#### Deadline:

November 15, 2017

#### Manuscript

#### Details &

#### Submission:

[www.jvsta.org](http://www.jvsta.org)

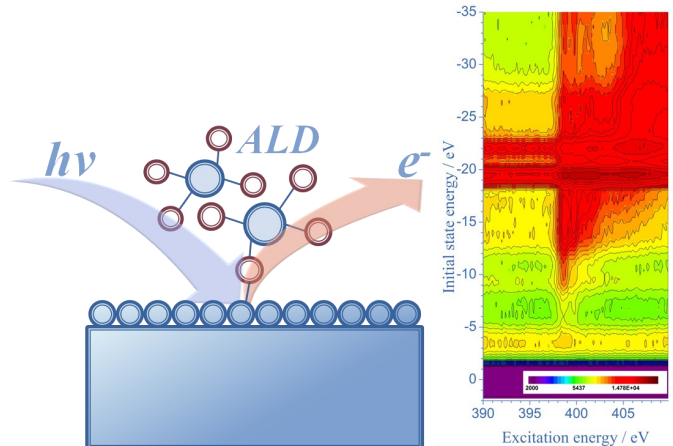
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10.1116/1.4978026

Papers will be reviewed using the same criteria as regular JVST articles and must meet JVST standards for both technical content and written English. To be published in JVST, the manuscript must:

- (1) present original findings, conclusions or analysis not previously published,
- (2) be free of errors and ambiguities,
- (3) support conclusions with data and analysis,
- (4) written clearly, and
- (5) have high impact in its field.



Online, tell us that your paper is a part of the special issue by choosing “Special Issue: Synchrotron Radiation and Atomic Layer Deposition for Advanced Materials.” Papers will appear online in the Special Issue as soon as they are accepted.

